

New multifunctional sulfonato-containing metal phosphonates proton conductors

Inés Ruiz-Salcedo,¹ Aurelio Cabeza,¹ Montserrat Bazaga-García,¹ Rosario M. Pérez-Colodrero,² Konstantinos Xanthopoulos,³ Konstantinos D. Demadis,³ Norbert Stock,⁴ Enrique R. Losilla,¹ Pascual Olivera-Pastor¹

¹ *Departamento de Química Inorgánica, Universidad de Málaga, Campus Teatinos s/n, 29071-Málaga, Spain*

² *Faculty of Science and Engineering Technology Centre, University of Wolverhampton, Wulfruna Campus, M I Building, Wolverhampton, UK.*

³ *Department of Chemistry, University of Crete, Greece*

⁴ *Christian-Albrechts-Universität, Kiel, Germany*

Anchoring of acidic functional groups to organic linkers acting as ligands in metal phosphonates has been demonstrate to be a valid strategy to develop new proton conductor materials, which exhibit tunable properties and are potentially applicable to proton exchange membranes, such as those used in PEMFCs [1,2].

In this work, the structural and proton conductivity properties of several families of divalent and trivalent metal amino-sulfophosphonates are presented. The chosen ligand, $(\text{H}_2\text{O}_3\text{PCH}_2)_2\text{-N-(CH}_2)_2\text{-SO}_3\text{H}$, was reacted with the appropriate metal salt using highthrough-put screening and/or microwave-assisted synthesis. Different crystal structures haven been solved displaying a variety of metal ligand coordination modes, in whose frameworks acidic groups contribute to create strong H-bond networks; together with lattice and bound water molecules. Proton conductivity values oscillate between 10^{-4} and 10^{-2} $\text{S}\cdot\text{cm}^{-1}$, at 80 °C and 95 % relative humidity, most of them showing activation energies characteristic of a Grotthuss-type proton transport mechanism.

References

[1] P. Ramaswamy, N.E. Wonga, G.K.H. Shimizu, *Chem. Soc. Rev.*, **2014**, *43*, 5913-5932.

[2] A. Cabeza, P. Olivera-Pastor, R.M.P. Colodrero, *Tailored Organic-Inorganic Materials*, Brunet, E., Colón, J.L, Clearfield, A., Eds.; John Wiley & Sons, Inc. **2015**; *Ch. 4*, 137-191.